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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1594**
Tuguto MARUKO : Attorney Docket No. 2003_1349A
Serial No. 10/673,572 : Group Art Unit 1756
Filed September 30, 2003 : Examiner Christopher G. Young
PHOTOMASK AND METHOD FOR : **Mail Stop Amendment**
EXPOSING CHIP PATTERN

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975

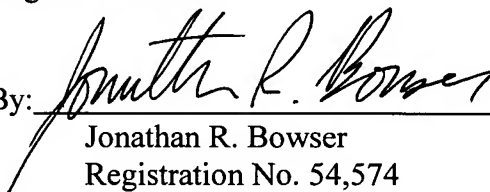
Sir:

In response to the restriction requirement contained in item 1 on page 2 of the Office Action dated May 19, 2006, the Applicant hereby elects **Group I**, which is drawn to a method. Claims 1-9 read on the elected invention.

Having made the required election, a full examination on the merits is respectfully requested.

Respectfully submitted,

Tuguto MARUKO

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May 30, 2006